

## CALIFORNIA STATE SCIENCE FAIR 2015 PROJECT SUMMARY

Name(s)		Project Number
Erika G. Yang		
		35489
Project Title		
Achieving Super Hydrophobic Surfaces as Water Repellent Materials)		
by Molecular Assembly of BCP and Plasma Dry Etch		
Objectives/Goals	Abstract	
	water repellant materials has g	reat interest due to its self-cleaning
function. The purpose of my expe	eriment was to explore the uses	of nano materials, such as block
copolymer and the plasma etch method to create the geometrical nano-structure on a silicon or glass substrate and then use the self-assembly of monolayer (PS-OH or PIPMS-OH) to themically modify the		
substrate and then use the self-ass	embly of monolayer (PS-OH conditions) of the superhydror	hobic surface can be used for many
applications and to find a much cl	heaper and effective var of do	ing it
Methods/Materials		
1) Polished 150 mm (6#) diameter		
2) 99.8% toluene used as solvent 3) Mono-hydroxyl-terminated pol	for polymer; hystyrene (PS-OH) (Molecyle V	Veight $M_{\rm H} = 3700  {\rm g/mol}$ 1% Weight to
3) Mono-hydroxyl-terminated polystyrene (PS-OH) (Molecule Weight $Mn = 3700 \text{ g/mol}$ ) 1% Weight to weight (w/w) PS-OH in toluene;		
4) Poly (styrene-b-dimethylsiloxa	ne) (PS-b-PDMS) delock cop	olypher (Mn=13500-b-4000). 1%
PS-b-PDMS in toluene		
After being chemically modified with these nano-structures and through multiple trials, the surfaces show		
a super-hydrophobic surface. This type of surface can be very helpful because it cause any type of liquid		
that falls on it, to immediately run off of the surface of the application, and leaving no traces of water behind. In addition, the contact angle of the surface of the wafer was able to gain additional 30 degrees, making it even more greater than the average super hydrophobic surface by 20 degrees!		
making it even more greater than the average super hydrophobic surface by 20 degrees!		
Conclusions/Discussion		
The conclusion I came to was by	applying a nano-material of dir	rected self-assembly onto a silicon or
The conclusion I came to was by applying a nano-naterial of directed self-assembly onto a silicon or quartz wafer, it can form a super-hydrophobic surface with a greater contact angle, causing the water to be able to fell off more assily then interval and the process of it is a much		
able to fall off more easily than just a flat surface. Using nano-materials and the process of it is a much more cheaper and effective way that the traditional coating methods, and it can last longer as it is an		
etching, in addition to the object with the super hydrophobic surface being able to automatically self-clean		
itself every time.		
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Summary Statement		
Creating a super hydrophobic nanostructure surface to be used as a self-cleaning and protecting material		
for various applications.		
Help Received		
Used lab equipment under the supervision of Dr. Peter		